

**Amendment to the Abstract**

*Please amend the abstract as follows:*

A copper electroplating material capable of exhibiting increased easy-dissolution properties, to thereby minimize formation of an insoluble residue. Basic copper carbonate is formed in a reaction tank by deposition and heated to a temperature of between 250°C and 800°C and preferably between 350°C and 600°C in an atmosphere which does not form a reducing atmosphere ~~which does not form a reducing atmosphere~~, to thereby be subjected to thermal decomposition, resulting in providing easily soluble copper oxide. The copper oxide is washed with water and dewatered using, for example, a centrifugal separator. Then, the copper oxide is dried.